Femtocut®: A system for Nanoprocessing with femtosecond laser pulses

Ronan Le Harzic¹, Sven Martin¹, Jens Kobow¹, Iris Riemann² and Karsten König¹,²
¹JenLab GmbH, Schillerstr. 1, 07745 Jena, Germany
²Fraunhofer IBMT, Ensheimer Str. 48, 66386 St. Ingbert, Germany
e-mail: info@jenlab.de, www.jenlab.de

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ABSTRACT

Femtocut® is a powerful tool for a few microns to sub-µm processing in several materials like dielectrics, polymers and metals as well as biological cells or tissues [1]. By using High numerical aperture objectives, it is possible to obtain once sub-µm features from a near-infrared (NIR) femtosecond laser-scanning microscope. With such a system it is obviously possible to obtain fluences in the range of a few hundred mJ to a few J/cm² above the ablation threshold of lots of materials even with a simple oscillator (nJ) which is a cost-effective and reliable system compared to amplified lasers systems (µJ or mJ/pulse).

The system is based on a microscope supplemented with a scanning unit. The scanning unit is optimized for usage of near infrared femtosecond pulsed laser beam. The scanning unit consist of a galvoscanner, a beam expander, a power meter and power adjustment by filter turret or continuously with a Glan-Calci polarizer as well as a control unit.

Figure 1: Laser dissection of human chromosomes